

UNITED STATES DEPARTMENT OF COMMERCE

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APPLICATION NO. **FILING DATE** FIRST NAMED INVENTOR ATTORNEY DOCKET NO. 09/492,243 01/27/00 HE M-7469-US **EXAMINER** 024251 MM91/1025 SKJERVEN MORRILL MACPHERSON LLP ORTIZ,E PAPER NUMBER 25 METRO DRIVE **ART UNIT** SUITE 700 SAN JOSE CA 95110 2815 **DATE MAILED:**

10/25/01

Please find below and/or attached an Office communication concerning this application or proceeding.

Commissioner of Patents and Trademarks

Office Action Summary

Application No. **09/492,243**

Applicant(s)

He Et.al.

Examiner

Edgardo Ortiz

Art Unit 2815



-- The MAILING DATE of this communication appears on the cover sheet with the correspondence address --Period for Reply A SHORTENED STATUTORY PERIOD FOR REPLY IS SET TO EXPIRE 3 MONTH(S) FROM THE MAILING DATE OF THIS COMMUNICATION. - Extensions of time may be available under the provisions of 37 CFR 1.136 (a). In no event, however, may a reply be timely filed after SIX (6) MONTHS from the mailing date of this communication. - If the period for reply specified above is less than thirty (30) days, a reply within the statutory minimum of thirty (30) days will be considered timely. - If NO period for reply is specified above, the maximum statutory period will apply and will expire SIX (6) MONTHS from the mailing date of this communication. - Failure to reply within the set or extended period for reply will, by statute, cause the application to become ABANDONED (35 U.S.C. § 133). - Any reply received by the Office later than three months after the mailing date of this communication, even if timely filed, may reduce any earned patent term adjustment. See 37 CFR 1.704(b). 1) Responsive to communication(s) filed on Oct 9, 2001 2a) This action is **FINAL**. 2b) This action is non-final. 3) Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under Ex parte Quayle, 1935 C.D. 11; 453 O.G. 213. Disposition of Claims 4) Claim(s) 1-4 and 9-12 is/are pending in the application. 4a) Of the above, claim(s) is/are withdrawn from consideration. 5) ☐ Claim(s) is/are allowed. 6) 💢 Claim(s) <u>1-4 and 9-12</u> is/are rejected. 7) L Claim(s) _____ is/are objected to. 8) Claims ______ are subject to restriction and/or election requirement. Application Papers 9) The specification is objected to by the Examiner. 10) The drawing(s) filed on ______ is/are objected to by the Examiner. 11) The proposed drawing correction filed on ______ is: a) approved b) disapproved. 12) \square The oath or declaration is objected to by the Examiner. Priority under 35 U.S.C. § 119 13) Acknowledgement is made of a claim for foreign priority under 35 U.S.C. § 119(a)-(d). a) \square All b) \square Some* c) \square None of: 1. Certified copies of the priority documents have been received. 2. Certified copies of the priority documents have been received in Application No. 3. Copies of the certified copies of the priority documents have been received in this National Stage application from the International Bureau (PCT Rule 17.2(a)). *See the attached detailed Office action for a list of the certified copies not received. 14) Acknowledgement is made of a claim for domestic priority under 35 U.S.C. § 119(e). Attachment(s) 15) X Notice of References Cited (PTO-892) 18) Interview Summary (PTO-413) Paper No(s). 16) Notice of Draftsperson's Patent Drawing Review (PTO-948) 19) Notice of Informal Patent Application (PTO-152)

17) X Information Disclosure Statement(s) (PTO-1449) Paper No(s). 2

20) Other:

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DETAILED ACTION

This Office Action is in response to an election filed October 9, 2001 on which Applicant elected Group I (Claims 1-4 and 9-12).

Claim Rejections - 35 USC § 102

1 The following is a quotation of the appropriate paragraphs of 35 U.S.C. 102 that form the basis for the rejections under this section made in this Office action:

A person shall be entitled to a patent unless --

(b) the invention was patented or described in a printed publication in this or a foreign country or in public use or on sale in this country, more than one year prior to the date of application for patent in the United States.

Claims 1-4 and 9-12 are rejected 35 § 102 (b) as being anticipated by Chen et.al. (U.S. Patent No. 5,045,898). With regard to Claim 1, Chen teaches a plurality of floating gate transistors connected in series, each floating gate transistor formed in a well of a semiconductor substrate (51), source and drain (55) regions and a channel regions separating said source and drain regions, said channel with a non-uniform concentration of dopant (boron).

With regard to Claim 2, Chen teaches a non-uniform concentration comprising a retrograde concentration distribution in the direction from the surface of the substrate.

With regard to Claim 3, Chen teaches a non-uniform concentration comprising a lateral concentration distribution along the length of the channel that is higher in a region generally Art Unit: 2815

towards the central portion of the channel region and decreases toward the source and drain regions.

With regard to Claim 4, Applicant claims that "the non-uniform concentration is formed by a tilted ion implantation utilizing as a mask a gate structure of each floating gate NMOS transistor." This a product by process limitation. A "product by process" claim is directed to the product per se, no matter how actually made, In re Brown, 173 USPQ 685; In re Luck, 177 USPQ 523; In re Fessmann, 180 USPQ 324; In re Avery, 186 USPQ 161; In re Wertheim, 191 USPQ 90 (209 USPQ 554 does not deal with this issue); In re Marosi et al, 218 USPQ 289; and particularly In re Thorpe, 227 USPQ 964, all of which make it clear that it is the patentability of the final product per se which must be determined in a "product by process" claim, and not the patentability of the process, and that an old or obvious product produced by a new method is not patentable as a product, whether claimed in "product by process" claims or not. Note that applicant has the burden of proof in such cases, as the above case law makes clear.

With regard to Claim 9, Chen teaches an isolated gate floating gate NMOS transistor comprising in well structure of a substrate (51), a source and drain region (55) and a channel region separating the source and drain regions, said channel region an non-uniform concentration of a dopant (boron).

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With regard to Claim 10, Chen teaches a non-uniform concentration comprising a retrograde concentration distribution in the direction from the surface of the substrate.

With regard to Claim 11, Chen teaches a non-uniform concentration comprising a lateral concentration distribution along the length of the channel that is higher in a region generally towards the central portion of the channel region and decreases toward the source and drain regions.

With regard to Claim 12, Applicant claims that "the non-uniform concentration is formed by a tilted ion implantation utilizing as a mask at least part of a gate structure of said transistor." This a product by process limitation. A "product by process" claim is directed to the product per se, no matter how actually made, In re Brown, 173 USPQ 685; In re Luck, 177 USPQ 523; In re Fessmann, 180 USPQ 324; In re Avery, 186 USPQ 161; In re Wertheim, 191 USPQ 90 (209 USPQ 554 does not deal with this issue); In re Marosi et al, 218 USPQ 289; and particularly In re Thorpe, 227 USPQ 964, all of which make it clear that it is the patentability of the final product per se which must be determined in a "product by process" claim, and not the patentability of the process, and that an old or obvious product produced by a new method is not patentable as a product, whether claimed in "product by process" claims or not. Note that applicant has the burden of proof in such cases, as the above case law makes clear.

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Conclusion

2. Any inquiry concerning this communication or earlier communications from the examiner should be directed to Examiner Edgardo Ortiz (Art Unit 2815), whose telephone number is (703) 308-6183. In case the Examiner can not be reached by a direct telephone call, you might call Supervisor Eddie Lee at (703) 308-1690. Any inquiry of a general nature or relating to the status of this application should be directed to the Group 2800 receptionist whose telephone number is (703) 308-0956.

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